



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

December 11, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG755528404

LABORATORY GROWN DIAMOND

EMERALD CUT

10.67 X 7.67 X 5.19 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

4.09 CARATS

E

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

EXCELLENT

EXCELLENT

NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG755528404

PROPORTIONS

Medium

62%

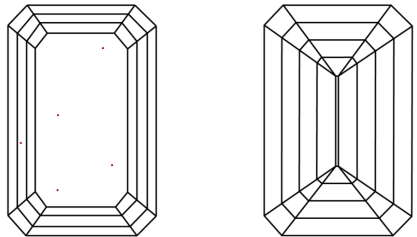
15.5%

49.5%

67.7%

Long

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS ¹⁻² VS ¹⁻² SI ¹⁻² I ¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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